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Spectral Sensitization of Semiconductors

with Phthalocyanine

by

⑩ Calvin D. Jaeger, Fu-Ren F. Fan and Allen J. Bard

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Spectral sensitization by metal-free phthalocyanine (H_2Pc) films was observed on various semiconductor electrodes (single crystal n-TiO_2, n-$SrTiO_3$, n-WO_3, n-ZnO, n-CdS, n-CdSe, n-Si, and n-GaP; SnO_2 conducting glass). The spectral response of the sensitized photocurrent was generally the same as the absorption spectrum of the phthalocyanine. The rather thick (400 Å to 1 μm) H_2Pc films showed both anodic and cathodic photocurrents depending upon the applied potential. The anodic photocurrents represented the usual

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SEMICONDUCTOR ELECTRODES. 26.

SPECTRAL SENSITIZATION OF SEMICONDUCTORS

WITH PHTHALOCYANINE

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(ABSTRACT)

Spectral sensitization by metal-free phthalocyanine (H_2Pc) films was observed on various semiconductor electrodes (single crystal $n\text{-}TiO_2$, $n\text{-}SrTiO_3$, $n\text{-}WO_3$, $n\text{-}ZnO$, $n\text{-}CdS$, $n\text{-}CdSe$, $n\text{-}Si$, and $n\text{-}GaP$; SnO_2 conducting glass). The spectral response of the sensitized photocurrent was generally the same as the absorption spectrum of the phthalocyanine. The rather thick (400 Å to 1 μm) H_2Pc films showed both anodic and cathodic photocurrents depending upon the applied potential. The anodic photocurrents represented the usual sensitization of the n-type semiconductor, while the cathodic photocurrents were attributed to p-type behavior of the phthalocyanine itself. The current-potential curves of the semiconductor electrodes depended on the nature of the H_2Pc film, the presence of a redox couple (i.e., p-hydroquinone/p-benzoquinone) in solution and the wavelength of the irradiating light. The magnitude of the steady state sensitized photocurrent was linear with light intensity and was strongly affected by the addition of a supersensitizer.

(End of Abstract)

Introduction

Many studies have been conducted utilizing dyes to sensitize reactions at semiconductor and metal electrodes.[1-5] Such sensitization is of interest, because it provides information about the nature of charge transfer between excited states and electrodes and, from a more practical standpoint, because it allows the utilization of longer wavelength light to promote photoprocesses at semiconductors. The problem with utilizing dye sensitization to increase the efficiency of semiconductor processes arises primarily from the relatively low absorbance of the monolayer films of dyes adsorbed on the surface. This results in a very low overall quantum efficiency in terms of incident (rather than absorbed) light. The use of concentrated solutions of dyes (>10^{-4} M) to maintain adsorbed monolayers can reduce the sensitized photocurrents, because the dye solution itself acts as a filter and thereby decreases the light intensity at the electrode surface. The use of thick insoluble dye films[6] has generally not proven successful because of the high ohmic resistance of these films. Gerischer has, in fact, suggested that not much can be gained by using dye multilayers because of the ohmic resistance to electron transfer and an increased quenching probability.[1] With the exception of sensitization by adsorbed dyes on sintered zinc oxide electrodes,[7] the overall quantum efficiency for these processes is usually quite small. We report here spectral sensitization on semiconductor electrodes by thicker metal-free phthalocyanine (H_2Pc) films (400 Å to 1 μm thick).

Sensitization by phthalocyanines is of interest for a number of reasons. Research on these materials has been very active recently,[8] and much is known about the redox behavior of these species in solution,[9-10] the catalytic activity of phthalocyanine electrodes (e.g., in fuel cells)[11-13] and their photoproperties.[14-17] These compounds have many characteristics which suggest

that they might be useful sensitizers for semiconductor electrodes: (1) They absorb light strongly in the visible region of the solar spectrum; (2) a wide variety of metal phthalocyanines have been prepared which allow a range of different compounds with different energy levels (i.e., redox potentials); (3) many phthalocyanines are readily available, very stable, and insoluble in water; (4) the redox behavior of these compounds has been studied extensively; (5) the phthalocyanines often exhibit semiconducting behavior.

The initial studies reported in this paper concern the utilization of films of H_2Pc primarily on single crystal n-type semiconductors. The results are discussed according to a   proposed mechanism of reactions of excited dye molecules on semiconductors[1] and the relative positions of the energy levels of the semiconductors, H_2Pc and the redox couples in solution. The action spectra of the sensitized photocurrent and the current-potential (i-V) behavior are presented. The dependence of the sensitized photocurrent on light intensity and the concentration of a supersensitizer in solution is discussed. The

stability of these systems both in the dark and under illumination and the p-type semiconductor properties of the H_2Pc films are also described.

Experimental

Materials. The metal-free phthalocyanine was purchased from Eastman (Rochester, N.Y.) and purified by repeated sublimation. The single crystal semiconductors were obtained from several sources (CdSe and CdS, Cleveland Crystals; GaAs, GaP and Si, Monsanto; ZnO and $SrTiO_3$, Atomergic; TiO_2, Fuji Titanium; WO_3, Sandia). All of the semiconductors were n-type. Unless stated otherwise all other chemicals were reagent grade and the water had been triply distilled from an alkaline potassium permanganate solution. Ohmic contacts were made to the back of the semiconductors. An electrical contact

was made to this ohmic contact using silver conducting paint (Acme Chemicals, New Haven, Conn.). On the back and sides, five minute epoxy cement (Devcon Corp., Danvers, Mass.) was used to cover the electrode and mount the crystal to a glass tube.

The films were prepared by sublimation in a vacuum deposition apparatus (Vacuum Engineering Co., North Billerica, Mass.). The H_2Pc was placed in a porcelain crucible. The H_2Pc was heated under vacuum (10^{-5} to 10^{-6} torr) by means of a tungsten wire (0.060 inch in diameter). A current of 20 A, which corresponds to a crucible temperature of 400-450 °C, was passed through the wire. The electrode substrate was about 25 cm above the crucible. The film thicknesses of the sublimed H_2Pc were determined by spectrophotometric methods, while that of thick films (>5000 Å) were based upon the weight and density of H_2Pc (1.5 g cm^{-3})[8b]. The absorbance at 5750 Å was measured for a 5000 Å film and from the known thicknesses an absorption coefficient of 4×10^4 cm^{-1} was found. Other film thicknesses were estimated by comparing their absorbances with that of the 5000 Å film. From the absorption spectrum the deposited H_2Pc is mainly in the α form.

Apparatus. The electrochemical cell utilized a three electrode system with a saturated calomel electrode (sce) reference and a platinum wire separated by a glass frit as the counter electrode. The cell had an optically flat Pyrex window on the side. Before all experiments the solutions were deaerated with prepurified nitrogen.

A PAR model 173 potentiostat and PAR model 175 universal programmer (Princeton Applied Research Corp., Princeton, N.J.) were used for the electrochemical experiments. The dc i-V curves were recorded directly from the output of the potentiostat on to a Houston Instruments (Austin, Texas) Model 2000 X-Y Recorder. The action spectra and the sensitized i-V behavior were

recorded using chopped light and a lock-in amplifier. Two different systems were used in these experiments. One system utilized a 2500 W xenon lamp and power supply (Schoffel Instr. Co., Westwood, N.J.), a monochromator (Jarrell-Ash, Waltham, Mass.), a PAR Model 192 variable frequency chopper, a PAR model 5204 lock-in amplifier and a Bascom-Turner 8110 recorder (Newton, Mass.). The other system used a 450 W xenon lamp and power supply (Oriel Corp., Stamford, Conn.), an Oriel Mono-chromator and a PAR HR8 lock-in amplifier. The light source used in the intensity and concentration studies was a Spectra Physics Model 132 He-Ne laser. All photocurrent-action spectra have been normalized against the power output of the lamp-monochromator.

Results and Discussion

Energy Levels and Mechanism for Photosensitized Currents. The relative energy levels for the n-type semiconductors studied along with H_2Pc and several redox couples are given in Fig. 1. The Fermi level at the flat-band potential (V_{fb}) for the semiconductors lies just below their respective con-duction band (CB) edges. For bulk H_2Pc the Fermi level is found slightly closer to the valence band (VB) ($V_F = 0.5 \pm 0.1$ V, $V_{CB} = -1.1 \pm 0.1$ V, and $V_{VB} = +0.8 \pm 0.1$ V vs. nhe).[17] The location of the energy levels of the H_2Pc are relatively insensitive to pH[19] while those for most of the semiconductors shift with pH.[18,20] If not mentioned otherwise, all solutions were buffered at pH 7 (0.25 M phosphate buffer).

Both anodic and cathodic photocurrents attributable to light absorption by the H_2Pc were observed with a given semiconductor, depending upon the applied potential. The observed anodic sensitized current depended upon the relative position of the energy levels of the semiconductor and H_2Pc. For example, no anodic sensitization was observed for the n-GaP-H_2Pc electrode, because, as

shown in Fig. 1, the conduction band of GaP (at pH 7) lies above that of

H_2Pc. On the other hand, for the WO_3-H_2Pc electrode, an anodic sensitized

current was observed in the presence of hydroquinone (HQ) beginning at a

potential of $\sim$ -0.1 V vs. sce and reaching a limiting value at more positive

potentials. A cathodic photocurrent was found at more negative potentials

with benzoquinone (BQ) (Fig. 2). In this case, the respective Fermi levels

of $n-WO_3$ and H_2Pc are quite close with the conduction band edge of H_2Pc lying

above that of the WO_3.

To help explain the experimental results, we first describe the proposed

model for these photosensitized processes, as shown schematically in Fig. 3.

Because, for most of the cases discussed here, the H_2Pc films were thin ($\lesssim$400 Å)

and the carrier levels within these films was probably rather low, the space

charge region at the H_2Pc/semiconductor interface extends to the H_2Pc/solution

interface.[21] Thus a simplified parallelogram-shaped energy level diagram (rather

than a single Schottky barrier at the H_2Pc/semiconductor interface) was assumed

for the H_2Pc phase. Such a constant field approximation has been used for even

thicker films in solid state photovoltaic cells with H_2Pc.[16] When a sufficient

positive potential is applied and the electrode is illuminated (with light of

energy greater than the band gap energy (E_g) of the H_2Pc but lower than the E_g

for the semiconductor) an anodic current is observed (Fig. 3B). The electron-hole

pair formed in the H_2Pc film separates under the applied electric field and the

electron migrates to the semiconductor-H_2Pc interface while the hole moves to

the H_2Pc solution interface. An intermediate level has been proposed for phthalo-

cyanine[22] and such a level may be involved both in mediating electron transfer to

the conduction band of the semiconductor and hole transfer to a redox couple in

solution, as shown in Fig. 3B. When a negative potential is applied under illumi-

nation, causing band structure shown in Fig. 3C to exist, a cathodic photosensitized

current is observed. In this case, holes created within the H_2Pc migrate toward the substrate semiconductor while the electrons move to the solution interface. With a negative bias the applied potential causes the bands in the semiconductor to bend downward producing degeneracy at the surface of the n-type semiconductor. Its behavior approaches that of a metal and the observed photoeffects are due solely to the H_2Pc. The photogenerated holes in the H_2Pc can recombine with the electrons from the semiconductor either through the intermediate level or via the valence band of H_2Pc. Cathodic photocurrents on phthalocyanine-metal electrodes have been reported previously.[15] The redox couple (HQ/BQ) acts as a supersensitizer.[1]

Photocurrent-wavelength Response: Oxide Semiconductors. The anodic and cathodic photocurrent action spectra for the oxide semiconductor-H_2Pc electrodes are shown in Fig. 4. All curves represent irradiation with modulated light (100 Hz) and phase sensitive detection. In general, at applied potentials positive of the V_{fb} of the semiconductor, the photosensitized currents were anodic, while at potentials negative of V_{fb}, the photosensitized currents were cathodic. For example for H_2Pc on SnO_2 conducting glass (Fig. 4A), the SnO_2 glass acts only as a contact and the cathodic photoeffect is due solely to the H_2Pc. The photocurrent action spectrum (a) is very similar to the absorption spectrum of H_2Pc on glass (b). For the SnO_2-H_2Pc electrode, as the applied potential was made more positive, the intensity of the cathodic photocurrent decreased. As shown in Fig. 3, at more positive potentials a larger barrier for electron transfer from the SnO_2 to the H_2Pc would be present. Generally, as shown in Fig. 4, both the anodic and cathodic photosensitized currents with the other wide band gap oxide semiconductor-H_2Pc electrodes were all close to the absorption spectrum of H_2Pc. For the TiO_2 and $SrTiO_3$-H_2Pc electrodes, the magnitude of the photosensitized current was potential dependent. The cathodic photocurrent decreased as the applied potential was made more positive. Moreover at a given potential just positive of the V_{fb} of TiO_2 (or $SrTiO_3$), a cathodic

photosensitized current was observed at longer wavelengths ($\lambda > 500$ nm) and an anodic photocurrent due to the band gap excitation of the TiO_2 (or $SrTiO_3$) was found at shorter wavelengths ($\lambda < 450$ nm). Thus with the TiO_2 and $SrTiO_3$-H_2Pc electrodes there is a small potential region near V_{fb} where the energetics are favorable for electron transfers either to or from the H_2Pc.

Current-potential Behavior: Oxide Semiconductors. Generally, all of the oxide semiconductor-H_2Pc electrodes showed similar i-V behavior (see Figs. 2 and 5). For example, in Fig. 5 i-V curves for TiO_2 and TiO_2-H_2Pc electrodes for a 10 mM HQ solution under illumination with chopped light are compared. The light was chopped to show the difference between the dark and the photo-current. The photoresponse of the TiO_2-H_2Pc electrode under irradiation with light of energy less than the E_g for TiO_2 (i.e., with a yellow filter, Oriel G 772-4750, 50% transmittance, T, at 500 nm and <1% T at 465 nm) is shown in Fig. 5d. At negative potentials a cathodic photocurrent is observed due to the H_2Pc. At positive potentials, only a small photoanodic current attributable to H_2Pc sensitization is found. Moreover there is a potential region of about 0.2 volts (-0.225 V to -0.425 V vs. sce) where anodic and cathodic photocurrents under while light illumination are possible (depending on whether HQ or BQ is present in the solution), an anodic photocurrent due to the TiO_2 absorption and a cathodic photocurrent from the H_2Pc.   As shown in Fig. 5c, for the TiO_2-H_2Pc electrode in the presence of HQ an anodic spike is observed at potentials positive of V_{fb} when the electrode is illuminated; such a spike is not found on an uncoated TiO_2 electrode in the presence of HQ (Fig. 5b). This anodic spike can be attributed to photooxidation of H_2Pc at the TiO_2-H_2Pc interface by holes photogenerated in the TiO_2. This oxidized H_2Pc is reduced by the solu-tion HQ, but this rate may be sluggish because of the poor mobility of the charge carriers in H_2Pc.[24b] When the light is turned off, a cathodic dark current spike is observed at potentials between about 0.0 V and -0.325 V vs. sce. The dark

cathodic current spike might involve the back electron transfer from TiO_2 to the photooxidized H_2Pc and the reduction of BQ to HQ generated during the illumination period. Note that reduction of BQ to HQ is possible at potentials negative of 0 V vs. sce, as shown by the i-V curve at Pt (Fig. 5a). Such dark reduction processes do not occur at the uncoated TiO_2 electrode following photooxidation (Fig. 5b). This suggests that the H_2Pc on the electrode surface provides surface states or an intermediate level for this back electron transfer. Such behavior has been observed for other semiconductor electrodes.[23]

The i-V curves for the WO_3-H_2Pc electrode during illumination with light of less energy than E_g of WO_3 (i.e., $\lambda > 590$ nm) at potentials negative of V_{fb} show that the cathodic photocurrent is strongly affected by the presence of benzoquinone (Fig. 2C). In the case of the anodic sensitized photocurrent (Fig. 2B), the presence of hydroquinone (HQ) affects the photocurrent-potential behavior. Without HQ during a potential sweep, the anodic sensitized photocurrent reaches a maximum at about +0.05 V vs. sce and then decreases probably because the H_2Pc itself is oxidized. In the presence of HQ the sensitized photocurrent reaches a limiting value which is related to the concentration of HQ and its diffusion to the electrode surface.

Dependence of Sensitized Photocurrent to Light Intensity. The dependence of the sensitized photocurrent for the oxidation of HQ on light intensity for the TiO_2-H_2Pc (a) and WO_3-H_2Pc (b,c) electrodes is shown in Fig. 6. In both cases the photocurrent depends linearly on light intensity.[24a] These experiments were conducted with a He-Ne laser (1.7 mW, 632.8 nm) and neutral density filters to vary the light intensity. Based upon the maximum photocurrent (i_p) for a WO_3-H_2Pc (400 Å) electrode, the incident quantum efficiency, ϕ, was calculated for both the anodic and cathodic sensitization, by dividing the current flow by the incident light flux. The monochromatic quantum efficiency in terms of incident radiation was $\phi_a = 7.61 \times 10^{-5}$ for the anodic photocurrent ($i_p = 66$ nA) and $\phi_c = 4.03 \times 10^{-4}$ for the cathodic photocurrent ($i_p = 350$ nA). The efficiencies

in terms of absorbed photons, ϕ_a' and ϕ_c' are about 1.6×10^{-4} and 8.48×10^{-4}, respectively. The values for ϕ_a' and ϕ_c' are based upon an absorbance of 7×10^4 cm^{-1} for the 400 Å thick H_2Pc film. These low efficiencies indicate that considerable recombination must be occurring.

Dependence of Sensitized Photocurrent to Concentration of HQ/BQ. The steady state H_2Pc-sensitized photocurrent depended upon the addition of a suitable supersensitizer (Fig. 7). Thus for WO_3 at positive potentials, the addition of a small amount of HQ sharply increased the anodic photocurrent (curve a). A similar dependency was observed with TiO_2 (curve c). After this sharp increase at low concentrations, the current tended to level off, suggesting that internal electron-hole pair recombination, rather than the oxidation of the H_2Q was governing the current. A similar effect was observed for the cathodic photosensitized current at WO_3 (curve b). The sensitized photocurrents of the oxide semiconductors remained constant under extended irradiation. For example the photocurrents at WO_3-H_2Pc remained constant for at least three hours in the presence of HQ or BQ (Fig. 8). Note that in this experiment the cathodic photo-current was over 100 times larger than the anodic one. Similar stability was also found for H_2Pc films on TiO_2 and SnO_2.

H_2Pc Films on Small Band-gap Semiconductors. The behavior of semiconductors with E_g-values smaller than that of H_2Pc was also investigated. The primary motivation for these studies was the possibility that films of H_2Pc might stabilize the semiconductors from anodic photodissolution; previous attempts at such stabilization of semiconductors with metal[25,26] or TiO_2[27,28] films have been reported. Photosensitized cathodic currents attributable to H_2Pc could be observed, e.g. with n-Si (Fig. 9c); in this case the semiconductor again behaved as a contact to the H_2Pc film. The observed action spectra were somewhat broader than that predicted by the absorption spectrum of H_2Pc. For n-GaAs (Fig. 9a) anodic photosensitization would not be expected, since it absorbs light of longer wavelength than H_2Pc. In this case the H_2Pc layer merely

acted as a filter so that the observed anodic photoresponse was smaller with the H_2Pc film than in its absence.

We found no long term stabilization of the semiconductors CdS, CdSe, and GaP from photocorrosion by coating with even rather thick (1 to 1.5 μm) H_2Pc films under conditions where the bare electrodes corrode. The evidence for such instability of coated electrodes was the decreased photocurrents under intense band gap illumination (>100 mW/cm^2) for extended periods (longer than 4 hours) and the production of photocorrosion products on the electrode surface. We suggest, in line with previous studies involving coatings with TiO_2,[27,28] that the films have small holes or cracks which eventually allow decomposition re-actions of the substrate semiconductor. Additional evidence for incomplete coverage by the H_2Pc film is the observed shift in the potential for photo-sensitized anodic current onset with pH over a pH range of 1 to 9 ($\sim$63 $\pm$ 5 mV/ pH unit) for H_2Pc coated WO_3, $SrTiO_3$, and TiO_2 electrodes. Such a shift would appear unlikely for H_2Pc itself and signals some kind of involvement of the substrate material even for the photosensitized process.

Conclusions

The photosensitization of semiconductor electrodes by metal-free phthalo-cyanine films has been clearly shown.   The action spectrum of the sensitized photocurrent of semiconductor-H_2Pc electrodes where both anodic and cathodic photocurrents are observed, generally compares well with the absorption spectrum of H_2Pc. The sign of the photocurrent depends upon the applied potential. At potentials very positive of V_{fb} the effect is anodic and at very negative poten-tials it is cathodic. This effect is similar to that found by Honda, et.al.[15b] for films of metal phthalocyanines on semiconductors. The i-V curves show that the presence of the H_2Pc, and also of hydroquinone, markedly affect the behavior of an illuminated semiconductor electrode. The observation of dark cathodic peaks suggests the presence of some intermediate level within the band gap of the semiconductor-H_2Pc electrode. Generally, the dependence of the sensitized photocurrent on light intensity and concentration of the supersensitizer follows the behavior previously shown for dye sensitization on semiconductor electrodes. Although the quantum efficiencies for the observed photosensitized processes were small and we were unsuccessful in stabilizing small band gap semiconductors with such films, for the reasons listed in the introduction, phthalocyanines remain of interest for sensitizing semiconductor photoprocesses. Work is con-tinuing in this laboratory utilizing metal phthalocyanines with other p- and n-type semiconductor electrodes.

Acknowledgement

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Figure Captions

Fig. 1   Relative energy levels of semiconductors,[18] H_2Pc and redox couples;
at pH 7, vs. nhe.

Fig. 2   (A) Current-potential curves with a 0.5 $\underline{M}$ Na_2SO_4, 0.25 $\underline{M}$ phosphate
buffer, illuminated with light ($\lambda > 590$ nm). (a) WO_3 electrode
w/o BQ; (b) WO_3-H_2Pc electrode w/o BQ; (c) WO_3-H_2Pc electrode
w/8 $\underline{mM}$ BQ. Initial potential at zero-photocurrent potential.
(B) Current-potential behavior in a 0.5 $\underline{M}$ Na_2SO_4, 0.25 $\underline{M}$ phosphate
buffer, illuminated with light ($\lambda > 590$ nm). (a) WO_3 electrode
w/o HQ; (b) WO_3-H_2Pc electrode w/o HQ; (c) WO_3-H_2Pc electrode
w/10 $\underline{mM}$ HQ.   Initial potential at zero-photocurrent potential.
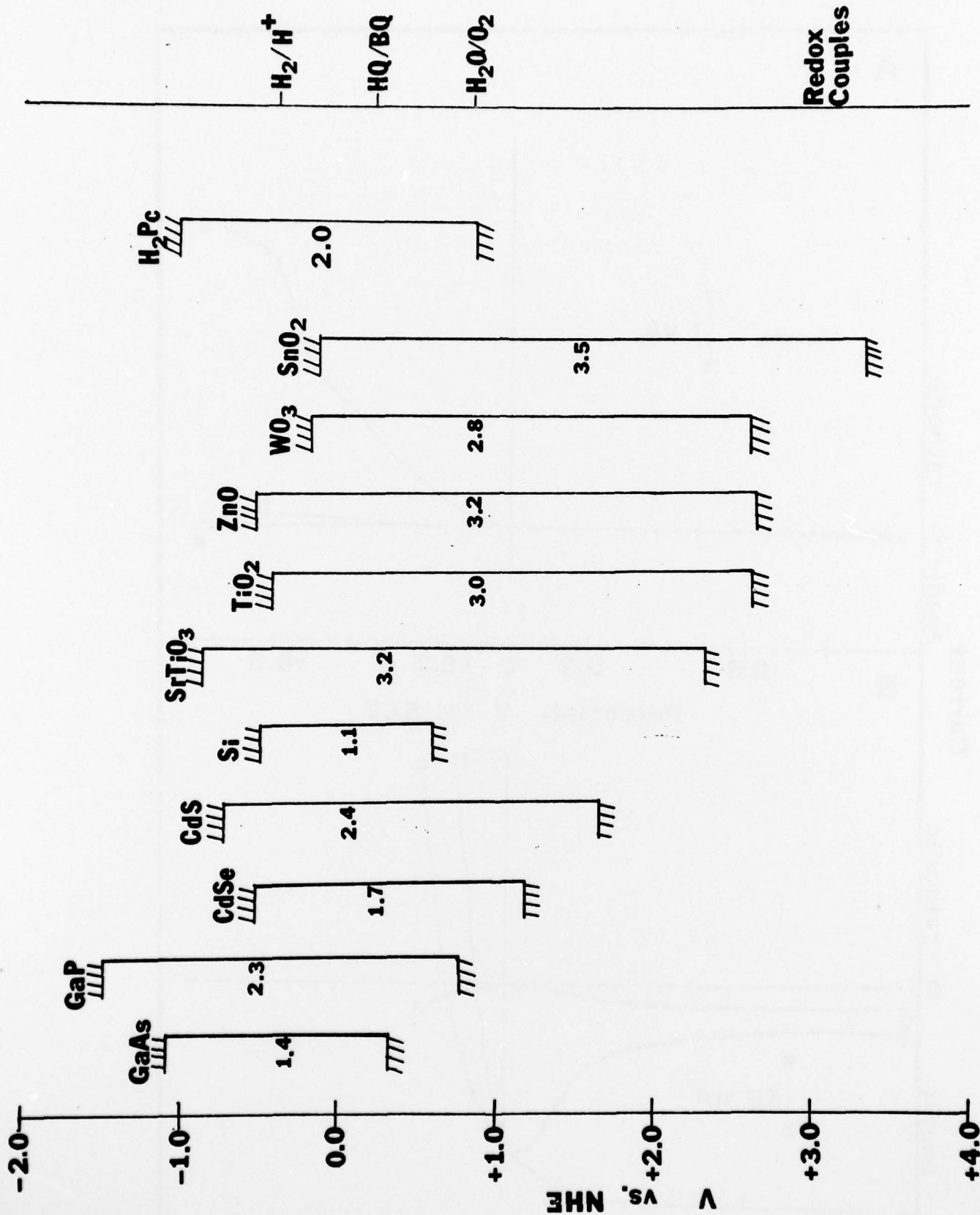
Fig. 3   Representation of photosensitized electron transfer. (A) Zero bias.
(B) At positive applied potentials. (C) At negative applied potentials.
E_c, E_f and E_v are the conduction band edge, the Fermi energy, and the
valence band edge of semiconductors; E_c' and E_v' are the corresponding
energies for H_2Pc.

Fig. 4   (A) (a) Photocurrent action spectrum for a SnO_2-H_2Pc electrode in
1 $\underline{M}$ KCl, 10 $\underline{mM}$ HQ, V = -0.6 V vs. sce; (b) absorption spectrum of
H_2Pc on glass.
(B) Photocurrent action spectrum for a WO_3-H_2Pc electrode in 0.5 $\underline{M}$
Na_2SO_4 and 0.25 $\underline{M}$ phosphate buffer (pH = 6.9). (a) anodic sensiti-
zation, V = +0.8 V vs. sce, w/50 $\underline{mM}$ HQ; (b) background photocurrent
of a WO_3 electrode; (c) cathodic sensitization, V = -0.7 vs. sce,
w/8 $\underline{mM}$ BQ.
(C) Photocurrent action spectrum for a TiO_2-H_2Pc electrode in 1 $\underline{M}$
KCl. (a) anodic sensitization, V = +0.4 V vs. sce, w/10 $\underline{mM}$ HQ;
(b) anodic sensitization, V = +0.2 V vs. sce, w/10 $\underline{mM}$ HQ; (c)
cathodic sensitization, V = -1.0 V vs. sce; (d) cathodic sensitiza-
tion, V = -0.4 V vs. sce.

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Fig. 4 (cont'd)   (D) Photocurrent action spectrum for a $SrTiO_3$-H_2Pc electrode in 1 $\underline{M}$ KCl. (a) anodic sensitization, V = -0.4 V vs. sce, w/10 m$\underline{M}$ HQ; (b) background photocurrent of a $SrTiO_3$ electrode, V = -0.4 V vs. sce; (c) cathodic sensitization, V = -0.6 V vs. sce.

Fig. 5   Current-potential curves with a HCl, NaCl, 10 m$\underline{M}$ HQ (pH 3.7) solution. (a) cyclic voltammogram of HQ/BQ on a Pt disk electrode; (b) TiO_2 electrode illuminated with chopped white light; (c) TiO_2-H_2Pc electrode illuminated with chopped white light; (d) TiO_2-H_2Pc electrode illuminated with chopped light (λ > 465 nm).

Fig. 6   Dependence of sensitized photocurrent on light intensity, 1.7 mW He-Ne laser (632.8 nm). (a) TiO_2-H_2Pc electrode in 1 $\underline{M}$ KCl w/10 m$\underline{M}$ HQ, V = +0.4 V vs. sce; (b) WO_3-H_2Pc electrode in 0.5 $\underline{M}$ Na_2SO_4, 0.25 $\underline{M}$ phosphate buffer (pH = 7), w/50 m$\underline{M}$ HQ, V = +0.8 V vs. sce; (c) WO_3-H_2Pc electrode in 0.5 $\underline{M}$ Na_2SO_4, 0.25 $\underline{M}$ phosphate buffer (pH = 7), w/8 m$\underline{M}$ BQ, V = -0.7 V vs. sce.

Fig. 7   Dependence of sensitized photocurrent on concentration of HQ/BQ. (a) WO_3-H_2Pc electrode in 0.5 $\underline{M}$ Na_2SO_4 and 0.25 $\underline{M}$ phosphate buffer (pH = 7), w/HQ, V = +0.8 V vs. sce; (b) WO_3-H_2Pc electrode in 0.5 $\underline{M}$ Na_2SO_4 and 0.25 $\underline{M}$ phosphate buffer (pH = 7), w/BQ, V = -0.7 V vs. sce; (c) TiO_2-H_2Pc electrode in 1 $\underline{M}$ KCl w/HQ, V = +0.4 V vs. sce.

Fig. 8   Stability of sensitized photocurrent in 0.5 $\underline{M}$ Na_2SO_4, 0.25 $\underline{M}$ phosphate buffer (pH = 7), light (λ > 590 nm), WO_3-H_2Pc electrode. (a) cathodic sensitized photocurrent, w/8 m$\underline{M}$ BQ, V = -0.7 V vs. sce; (b) anodic sensitized photocurrent, w/50 m$\underline{M}$ HQ, V = +0.8 V vs. sce.

Fig. 9   Action spectra for (a) anodic photocurrent at n-GaAs-H_2Pc, 1 $\underline{M}$ KCl, 10 m$\underline{M}$ HQ, V = -0.6 V vs. sce; (b) cathodic photocurrent at n-ZnO-H_2Pc, 1 $\underline{M}$ KCl, 10 m$\underline{M}$ BA, V = -1.0 V vs. sce; (c) as (b) for n-Si-H_2Pc, V = -1.0 V vs. sce.

Fig 2

Fig 4

Current

5μA
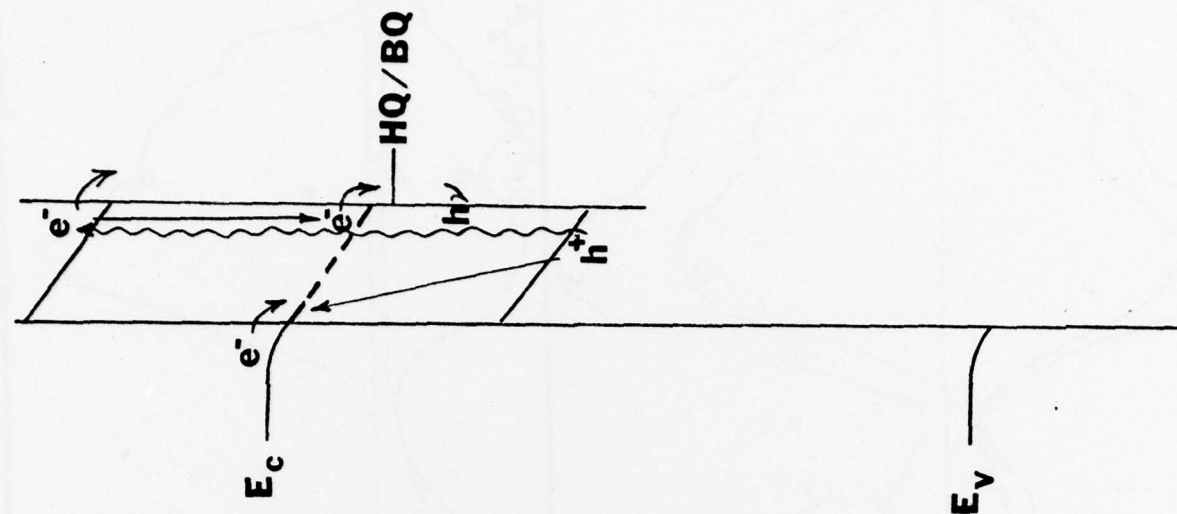
light on

light on

a

b

c

d

Potential, V vs SCE

+0.1   0.0   -0.1   -0.2   -0.3   -0.4   -0.5

Fig. 6
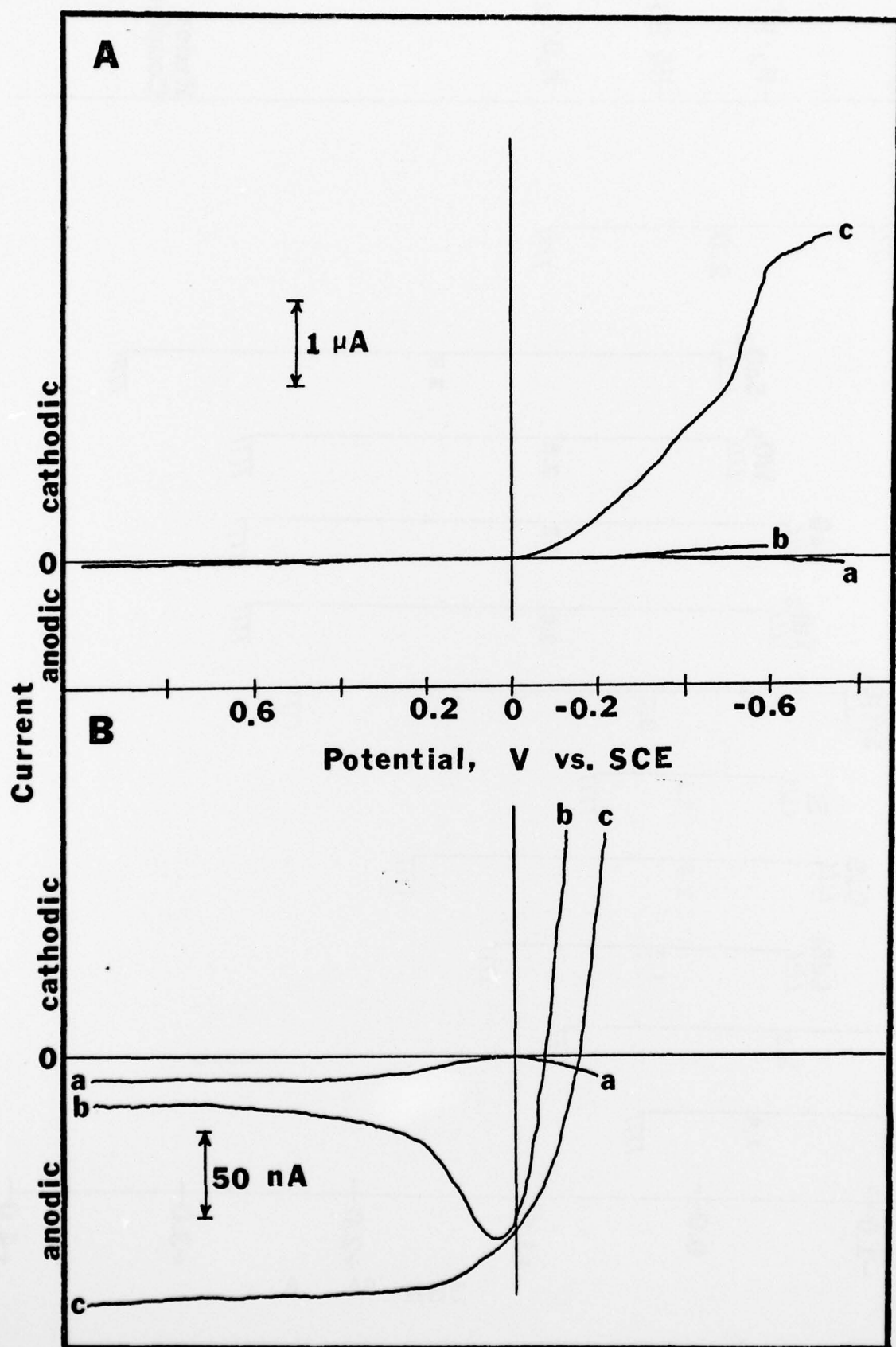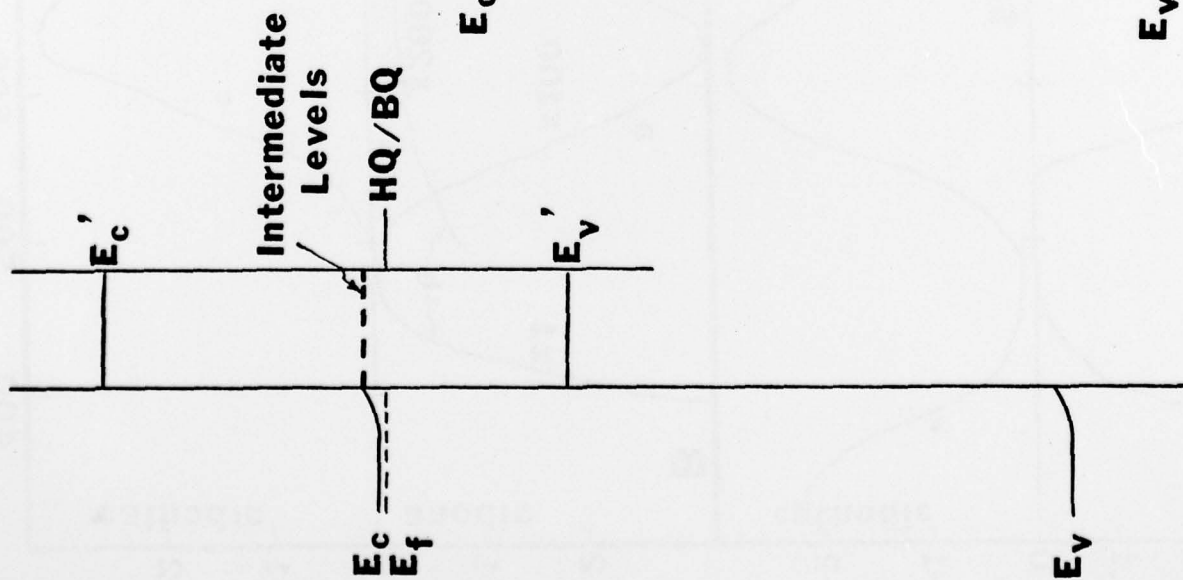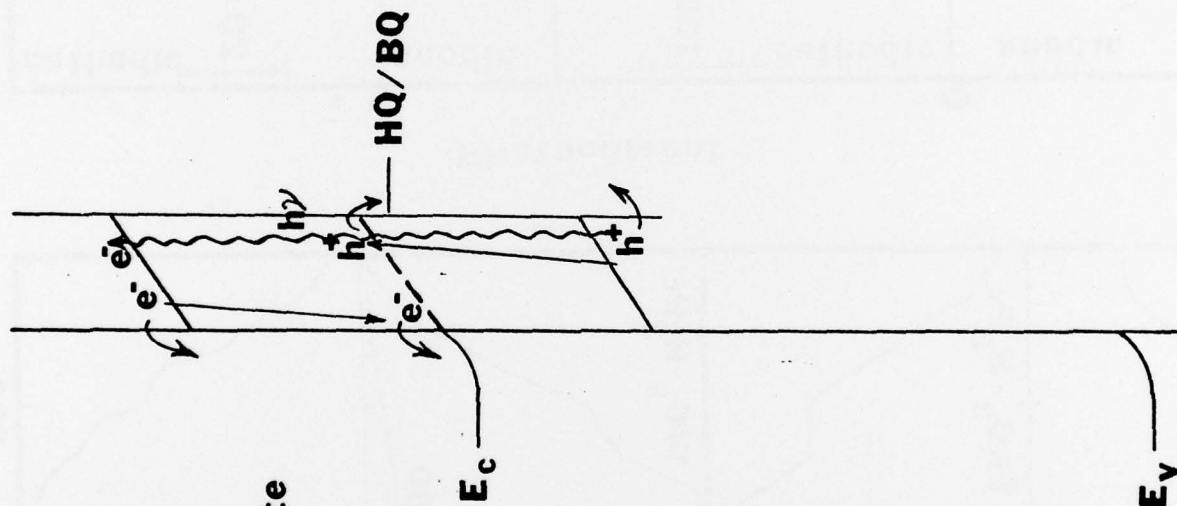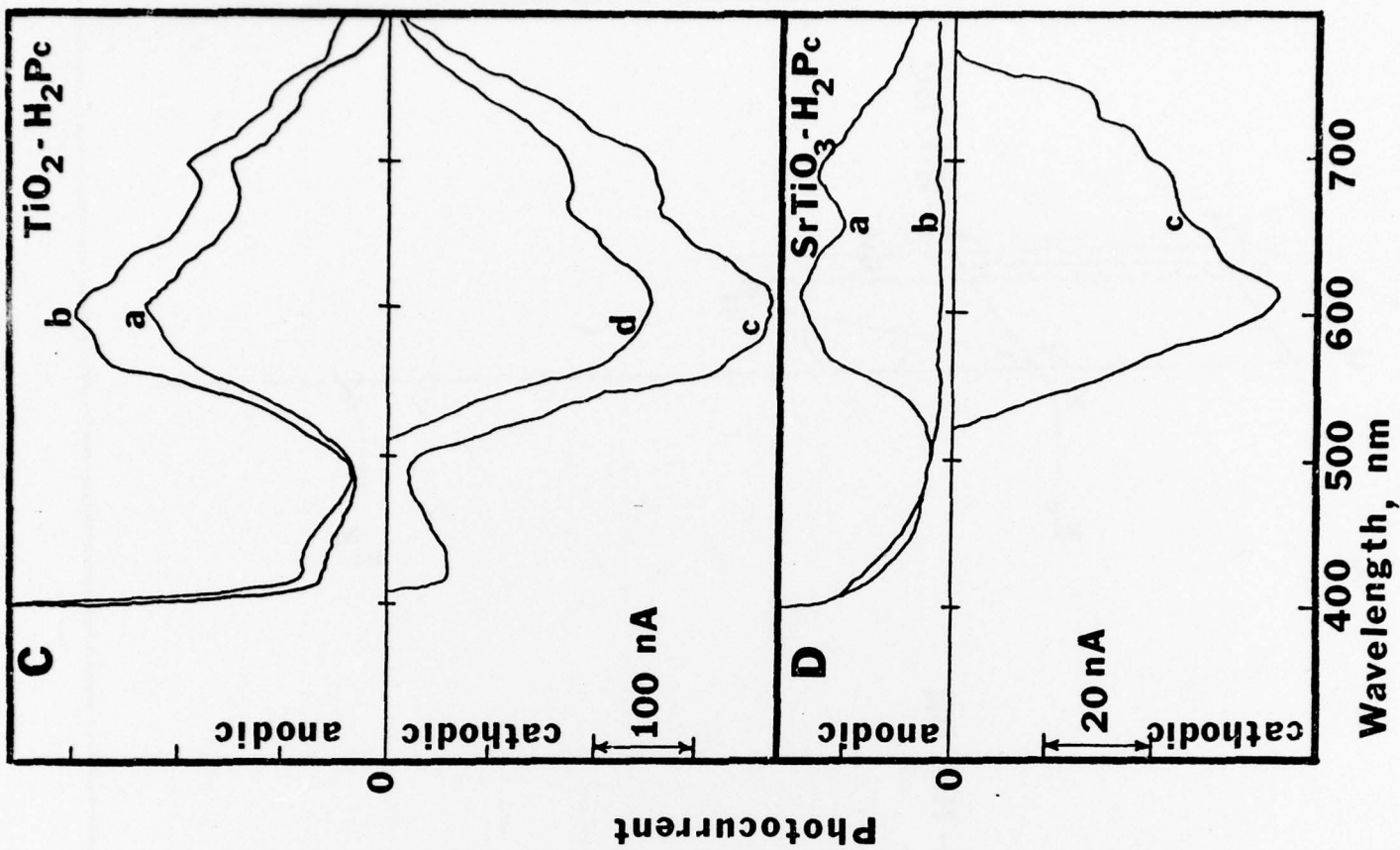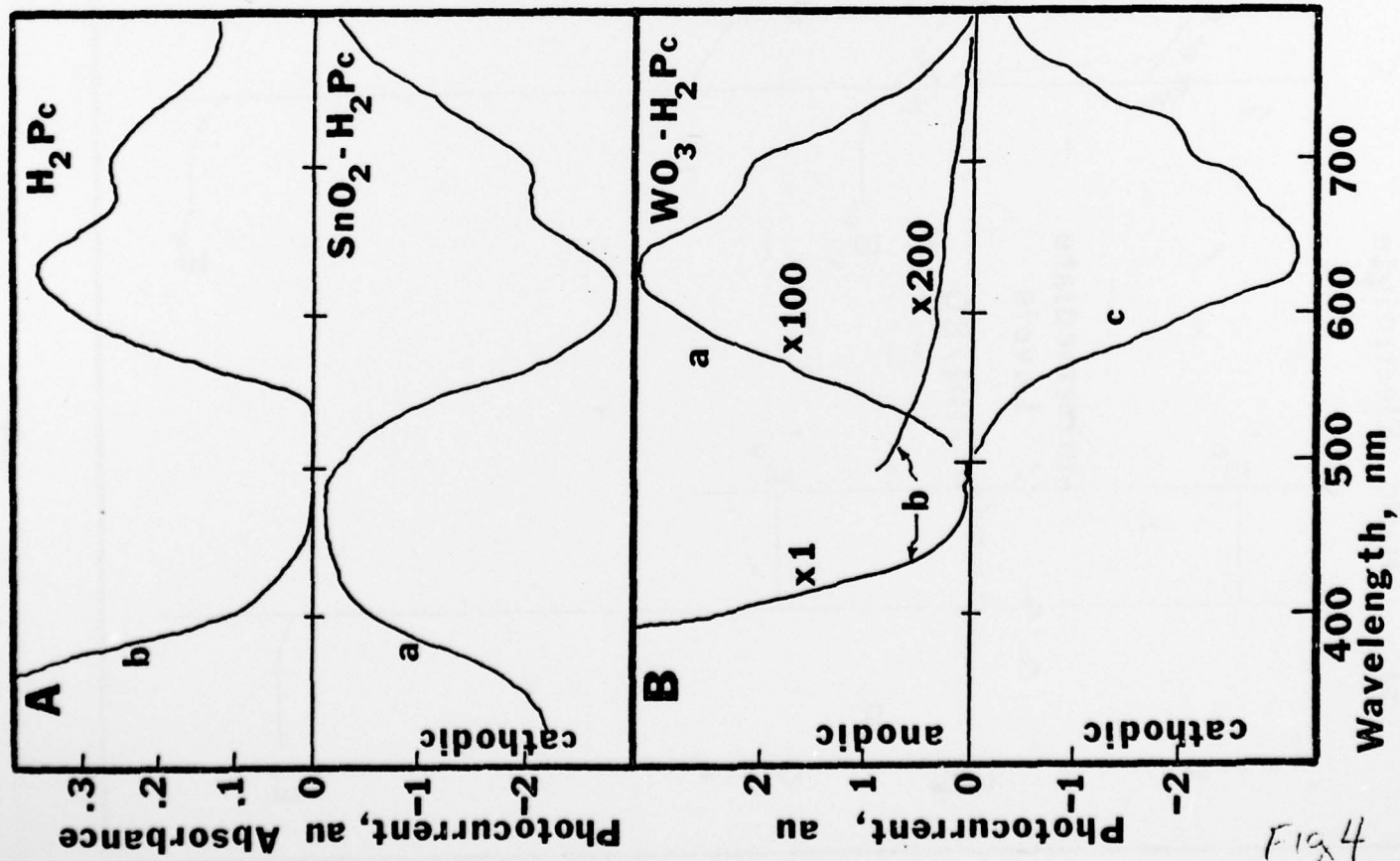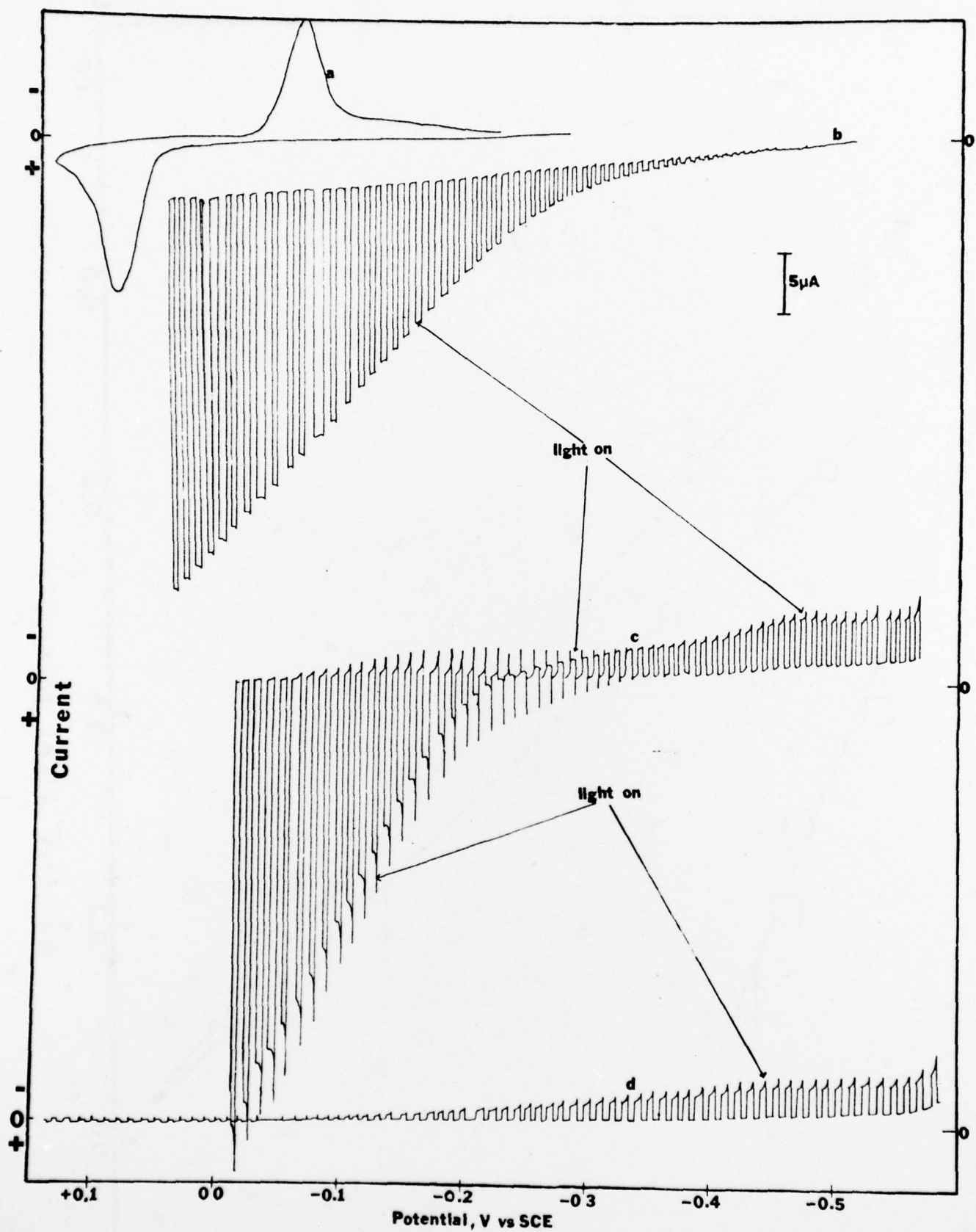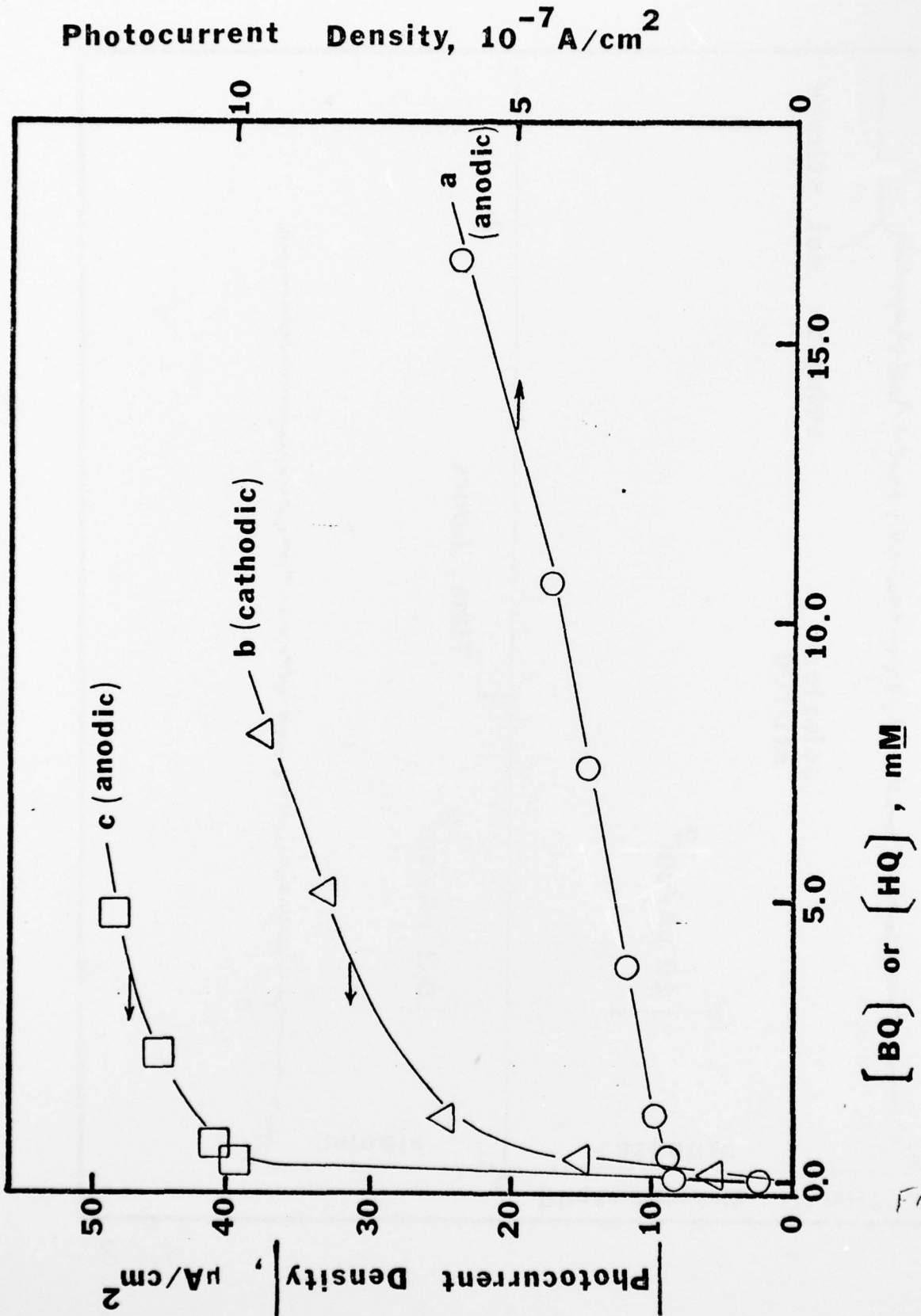
Fig. 7
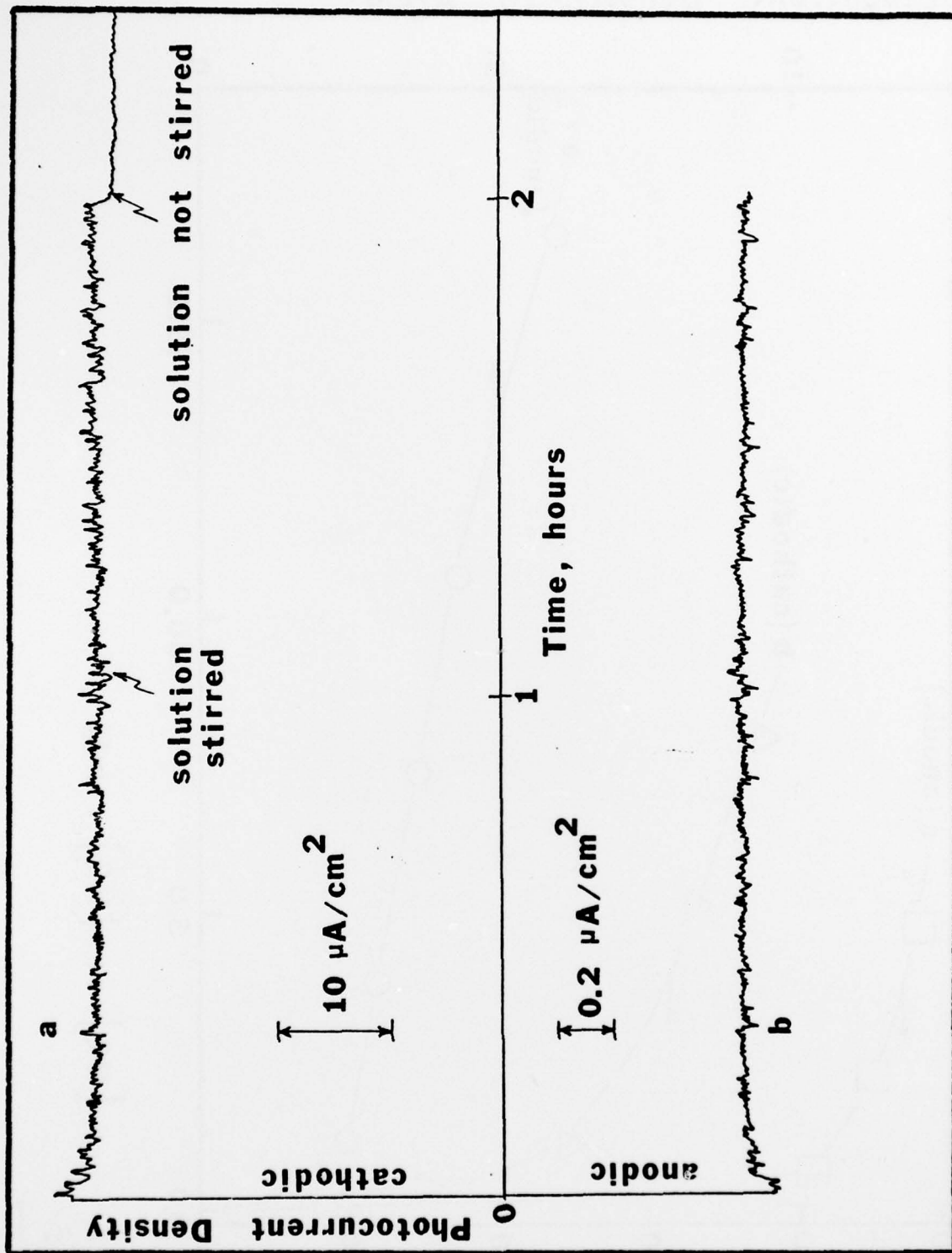
Fig 8
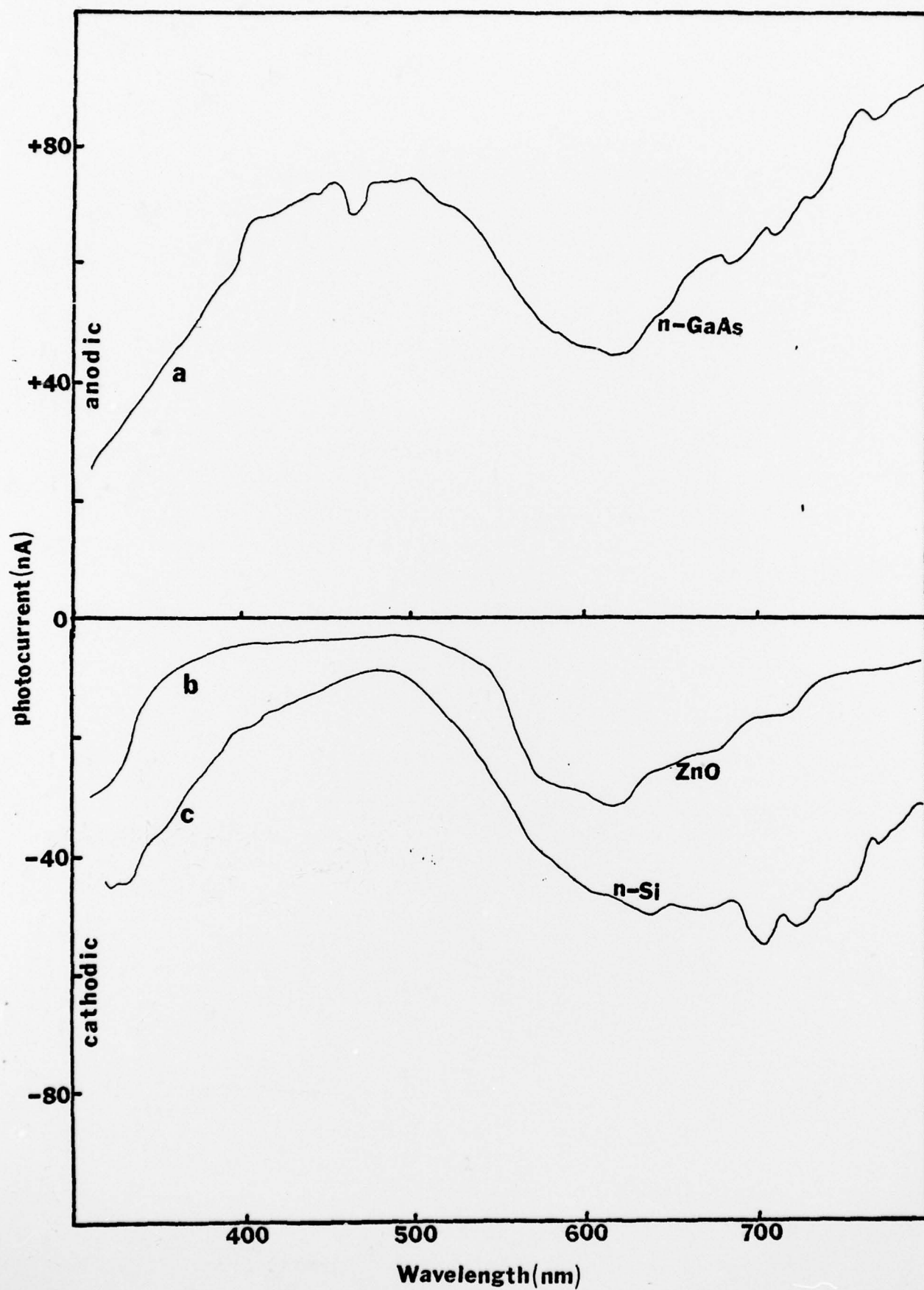
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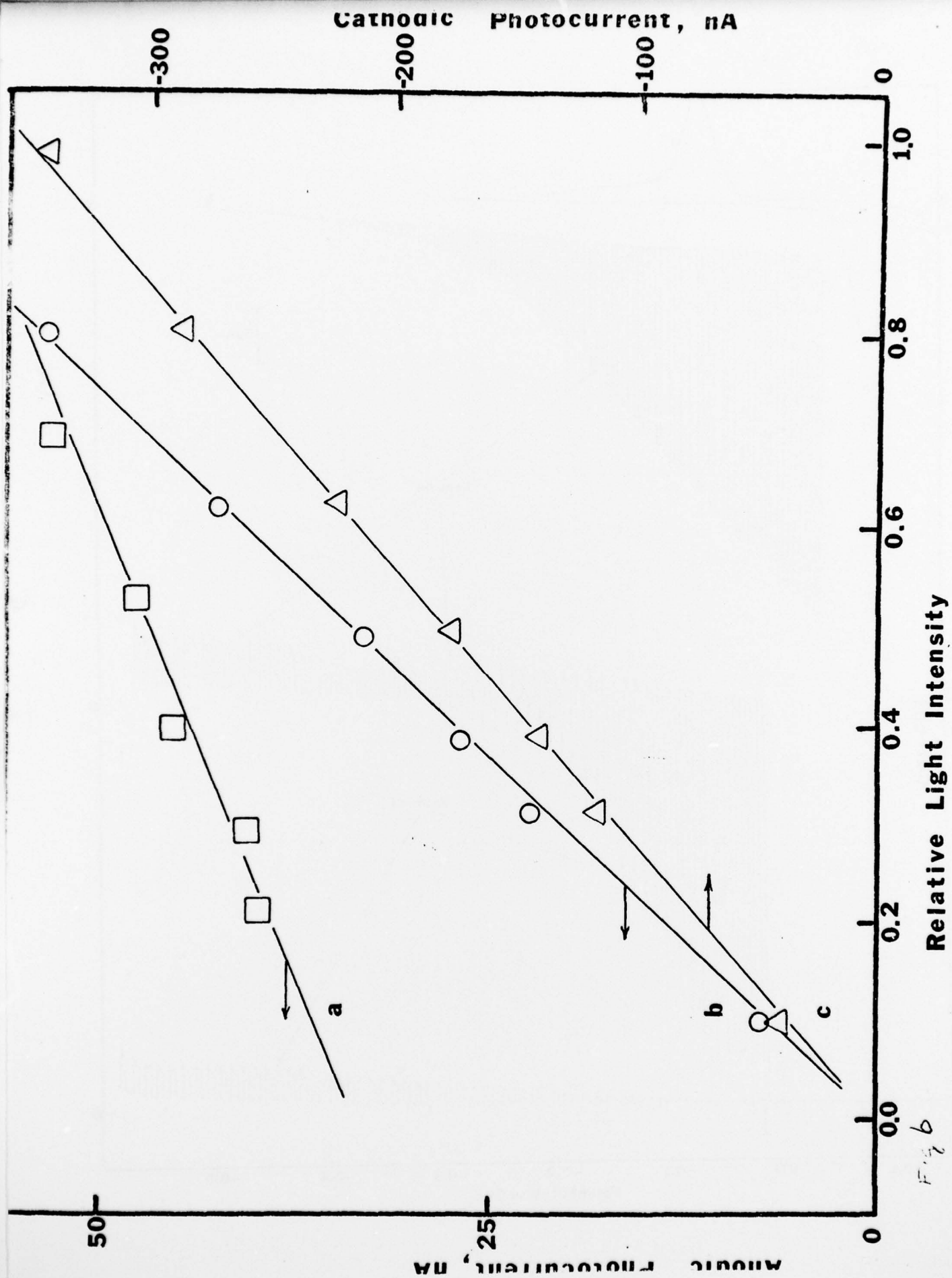|	No. Copies		No. Copies
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